



VACUUM OVEN

OUTSTANDING CHEMICAL AND CONDENSATE COMPATIBILITY WITH FAST EVACUATION OF LARGE VAPOR QUANTITIES

LABOPORT® SD



TRIED AND TESTED

N 820.3 FT.40.18 and N 840.3 FT.40.18 Diaphragm Vacuum Pump

- Flow rate up to 2.04 m³/h / Ultimate vacuum 10 mbar abs.
- Integrated KNF self-drying system ensures that condensate is quickly removed from the pump heads without the vacuum being altered. This significantly reduces process time and preserves the pump heads
- Chemically resistant and thus ideal for use with extremely aggressive/corrosive gases and vapors

A POWERFUL PACKAGE

N 860.3 FT.40.18 Diaphragm Vacuum Pump

- Flow rate 3.6 m³/h / Ultimate vacuum 4 mbar abs.
- Integrated KNF self-drying system ensures that condensate is quickly removed from the pump heads without the vacuum being altered. This significantly reduces process time and preserves the pump heads
- Chemically resistant and thus ideal for use with extremely aggressive/corrosive gases and vapors



LABOPORT®



SR 820 G

CHEMICALLY RESISTANT AND CONDENSATE COMPATIBILITY

SR 820 G and SR 840 G Vacuum System

- Flow rate up to 2.04 m³/h / Ultimate vacuum 6 mbar abs.
- Vacuum system comprising chemically resistant diaphragm vacuum pump, base plate and two separator flasks on suction and pressure side
- Integrated gas ballast valve

Possible combinations

When combined with the VC 900 vacuum control unit and the connection cable, the rotational speed is controlled in accordance with the requirements of the process. Ideal for combining with all common vacuum controllers with valve control.

